

IN THE SPECIFICATION

Please amend the specification as amended by Preliminary Amendment on January 20, 2004, on page 1, beginning at line 1:

~~This application is a continuation application of U.S. Serial No. 09/926,464 filed on January 10, 2002, pending, which is a 371 of International Application PCT/JP01/01787 filed on March 7, 2001.~~ This application is a continuation application of U.S. Serial No. 09/926,464 filed on January 10, 2002, now U.S. Patent No. 6,888,236, which is a 371 of International Application PCT/JP01/01787 filed on March 7, 2001.

Please replace the Title with the following Title:

~~CERAMIC SUBSTRATE FOR A SEMICONDUCTOR PRODUCING/EXAMINING
DEVICE~~ CERAMIC SUBSTRATE FOR MANUFACTURE/INSPECTION OF
SEMICONDUCTOR

Please amend the Abstract on page 54 as follows: